

W3+ FAIR JENA  
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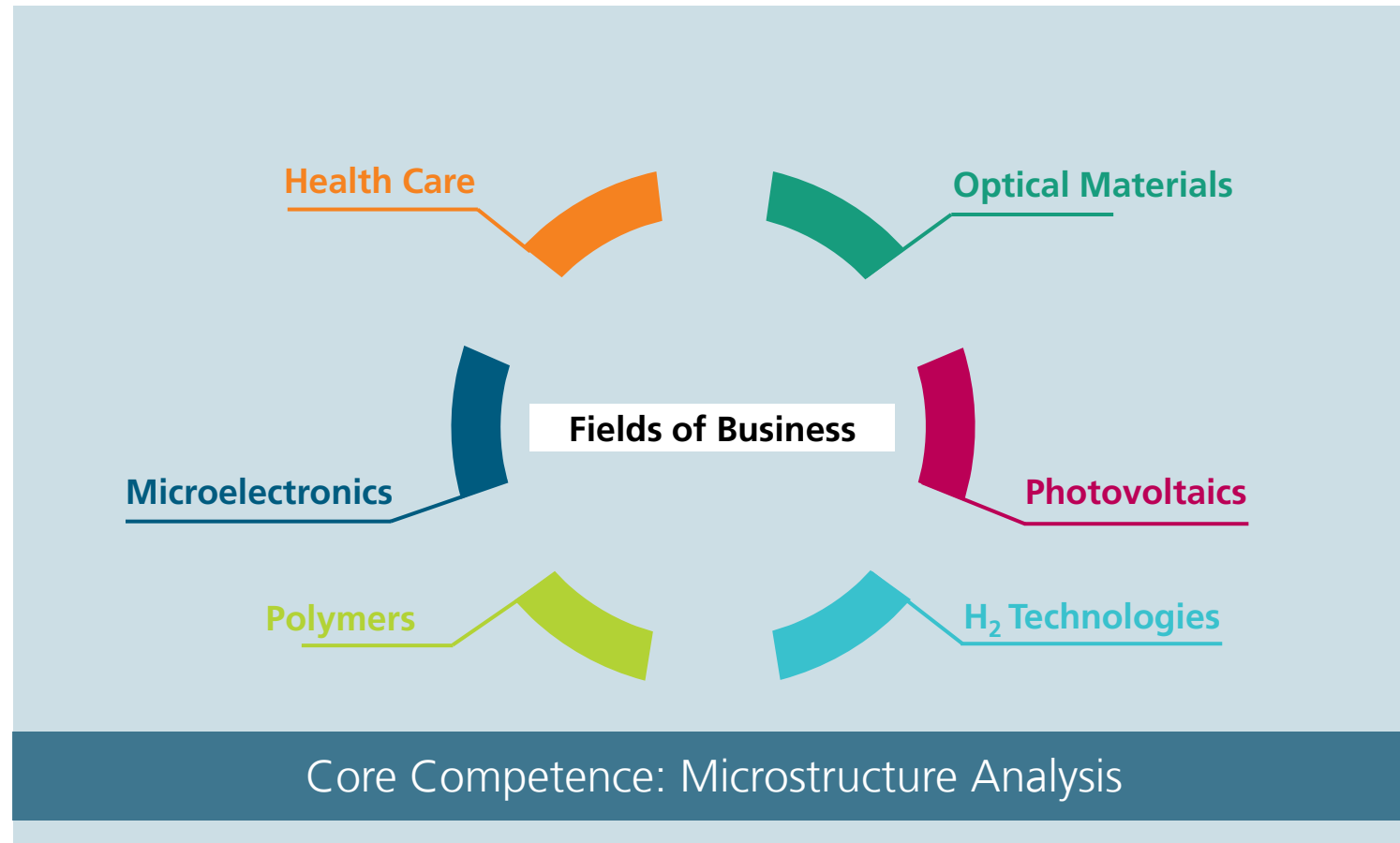
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# State of the Art Optical Thin Film Analyses for Industrial Applications

René Feder, Christian Patzig, Stephan Gierth, Alexander Kemptner, Thomas Höche

# Fraunhofer IMWS

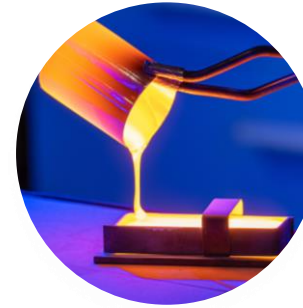
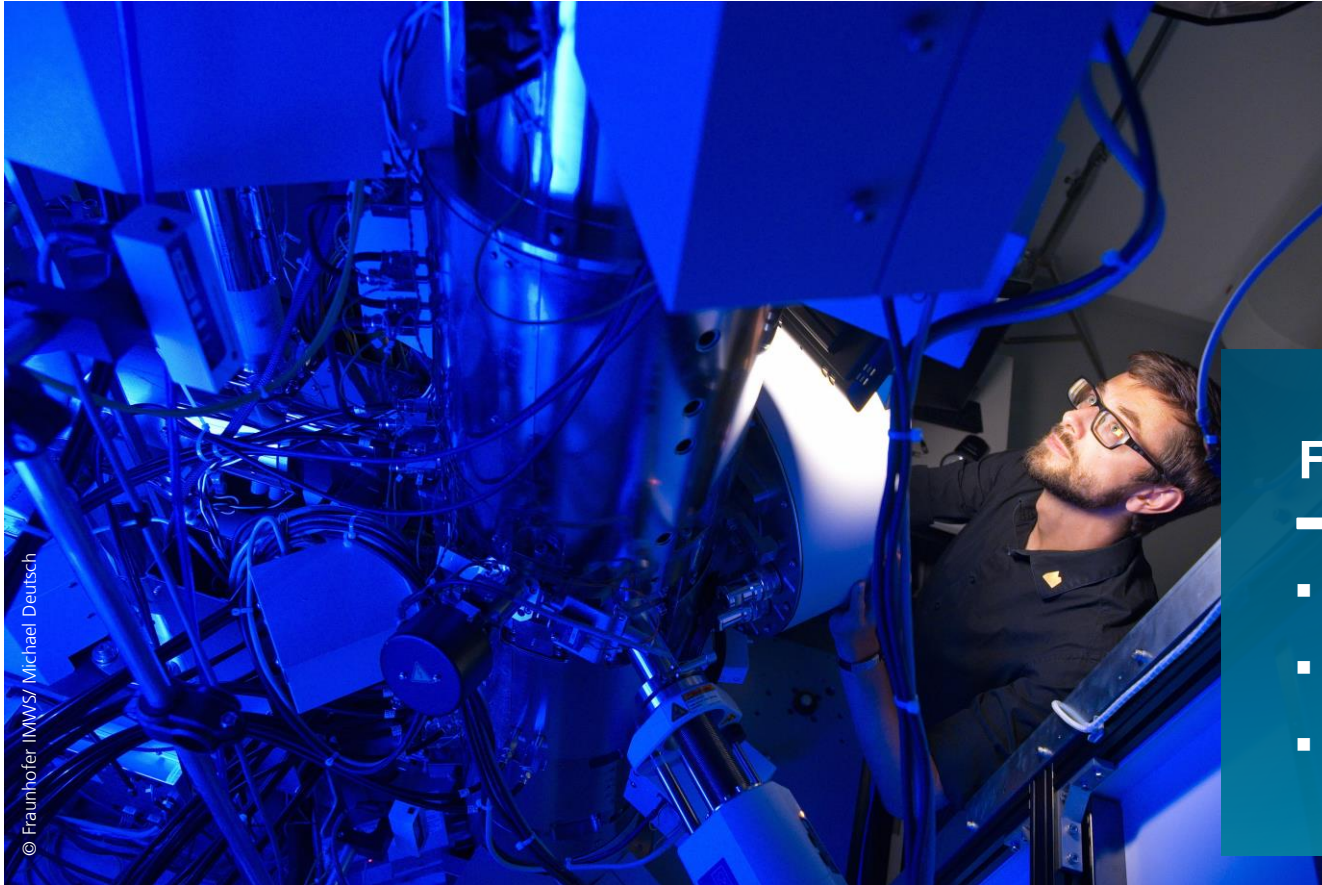
Who we are



The Fh IMWS is a methodologically oriented portfolio institute.

# Optical Materials

## Tailored microstructure diagnostics



### Focus and know-how

- Microstructure-based development of glasses and ceramics
- Microstructure-based laser process development
- **Microstructure analysis of thin films, glasses and ceramics**

# Optical Coatings

## Cutting Edge Analytical Techniques

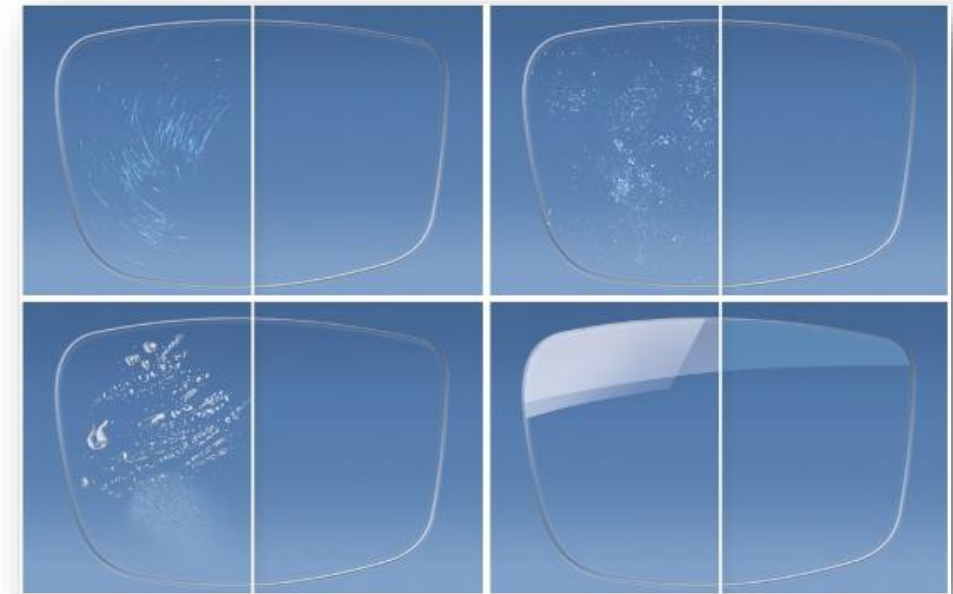


- FIB-SEM (+EDX)
  - Imaging of surfaces and cross sections
  - Composition (0.1at%)
- HR-(S)TEM (+EDX)
  - Cross section
  - Microstructure & composition
- ToF-SIMS
  - Surface analysis
  - Depth profiling
  - Contaminations (ppb)

# Ophthalmic lens coatings

## A complex hybrid system

- 2001: 23% short sighted world wide.
- Increasing in younger age groups.
- In 2050, 50% of the world population will be myopic.

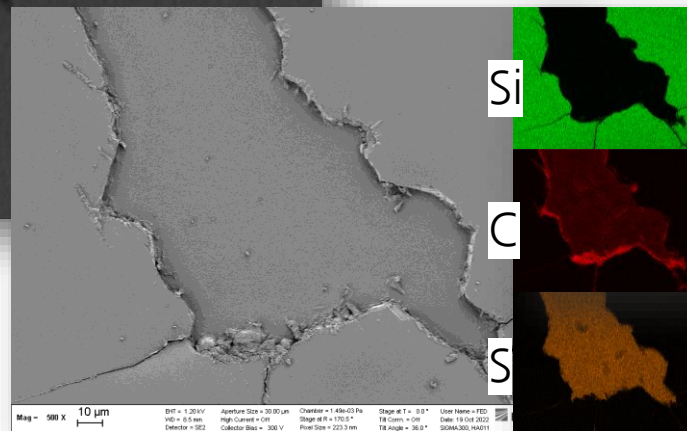
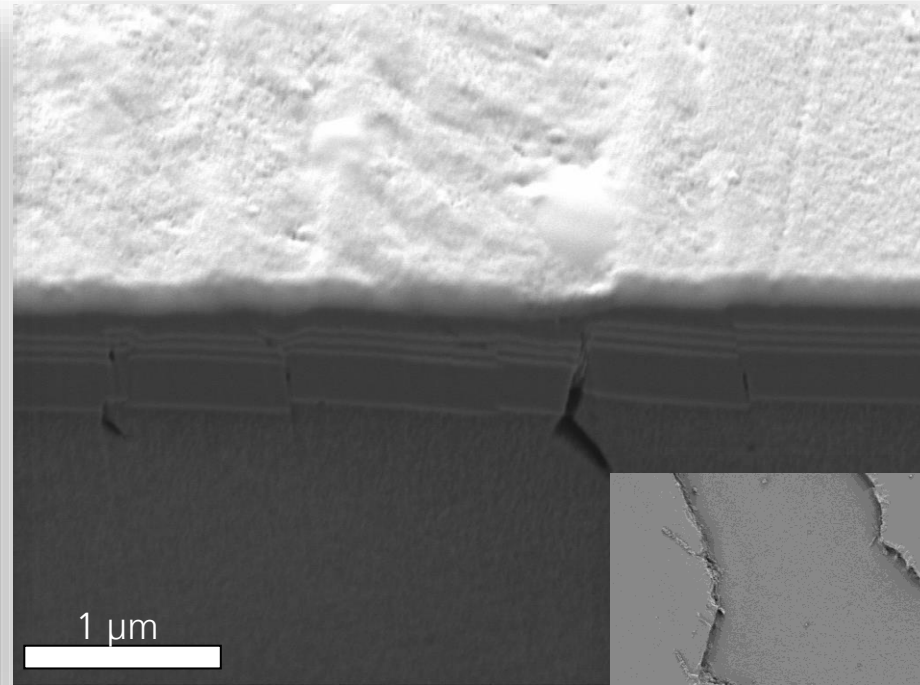


Typical coating stack

Layer	Thickness
Top coat	1-2 monolayers
Broadband anti-reflective	Few 100 nm
Anti-static (included in AR)	< 10 nm
Hard coating	~ 3 $\mu\text{m}$
Hard coating primer	~ 800 nm
Polymer substrate	~ mm

# Ophthalmic lens coatings

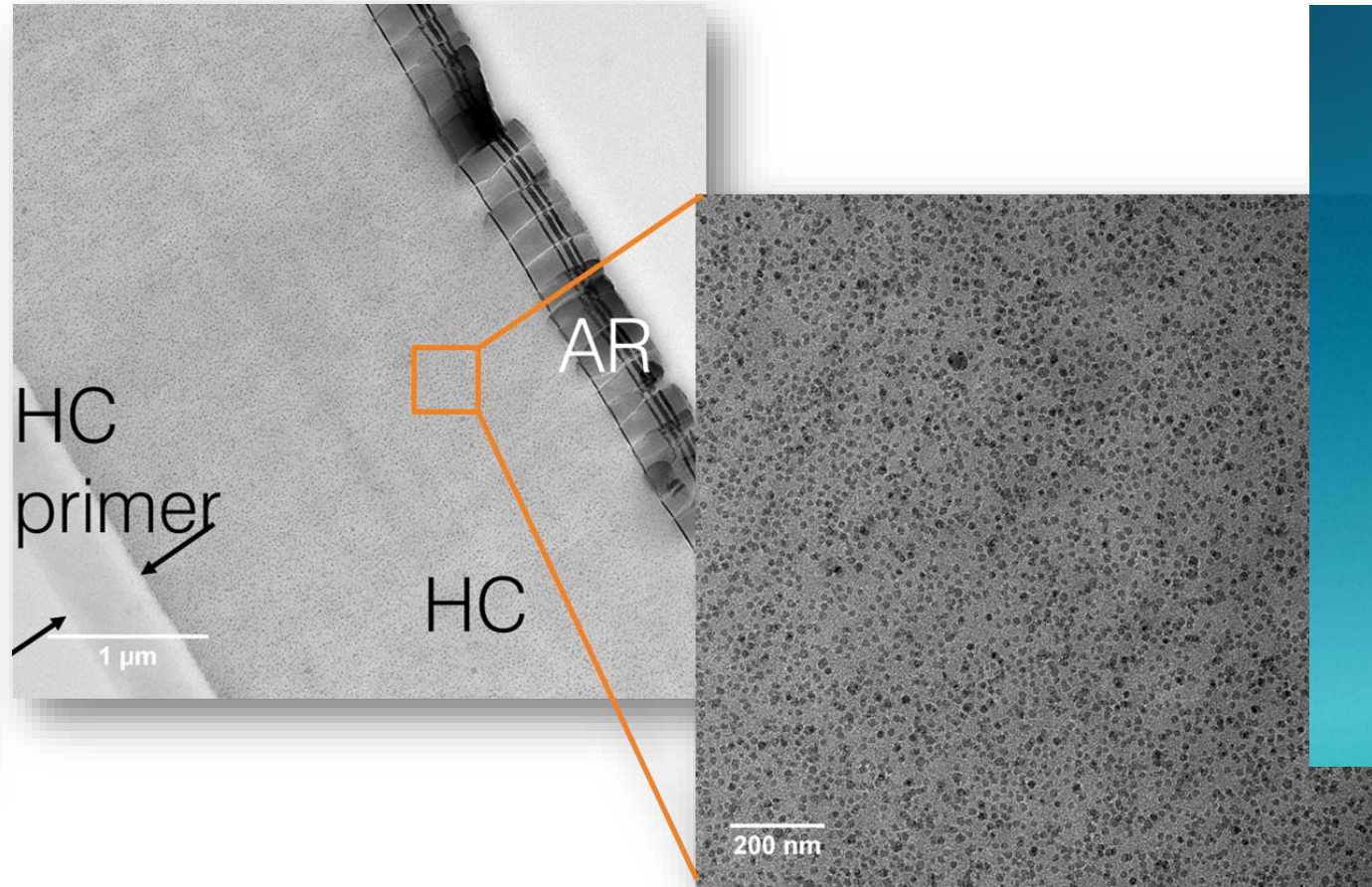
## SEM-FIB-EDX



- SEM: delamination of the coating system.
- FIB: cross sectioning
- EDX: Distribution of
  - Ti (AR),
  - S (substrate)
  - Si (AR and HC)
- Complete delamination of AR and hard coating

# Ophthalmic lens coatings

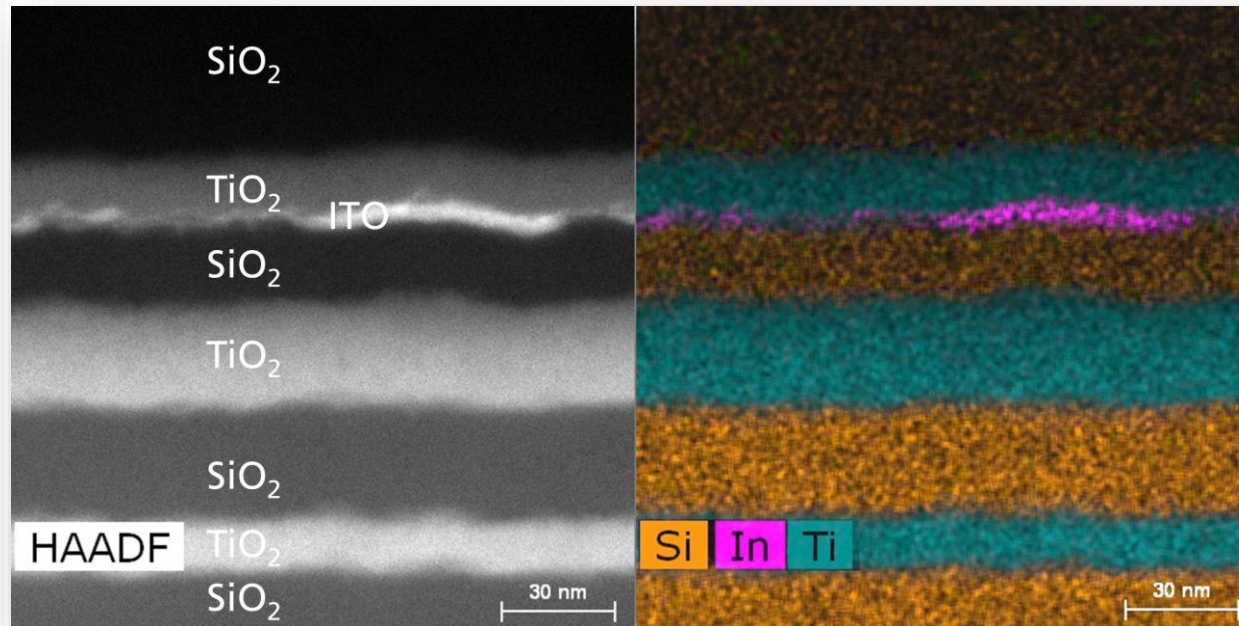
## HR-TEM



- TEM: high-res overview of the complete coating system (AR, hard coat, primer).
- Distribution, density gradients or agglomeration of nano particles can be detected.

# Ophthalmic lens coatings

## STEM-EDX

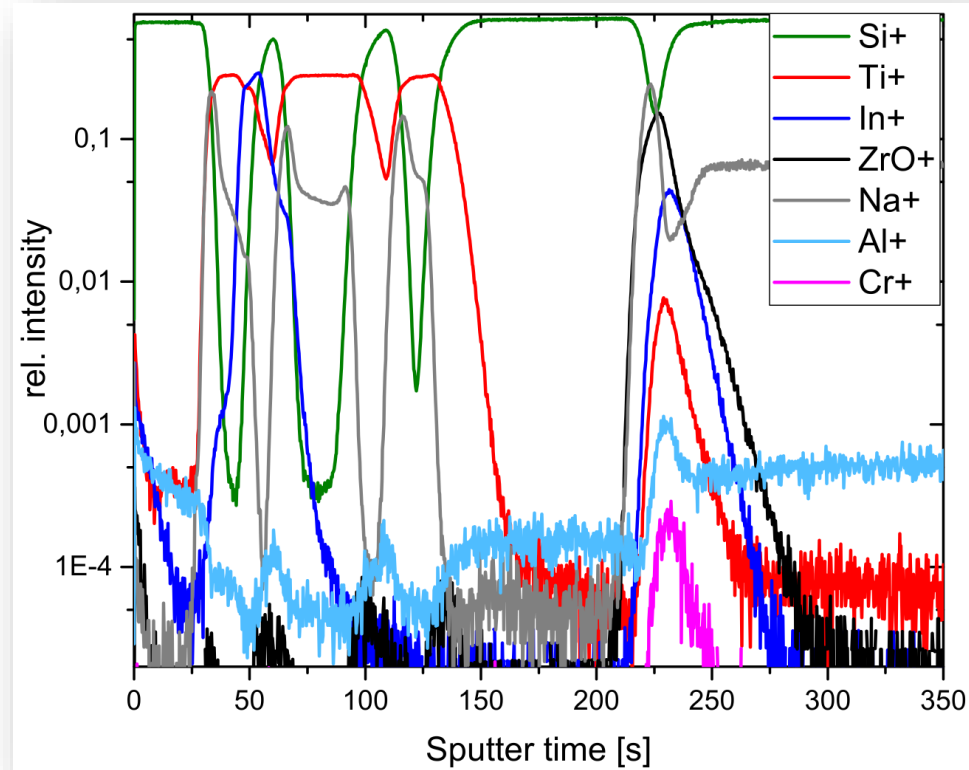


- STEM-EDX: high-res imaging and elemental distribution of the AR stack.
- Interface roughness, layer inhomogeneities and diffusion can be visualized.

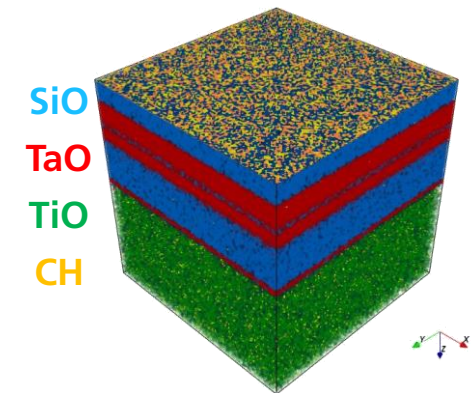


# Ophthalmic lens coatings

## ToF-SIMS

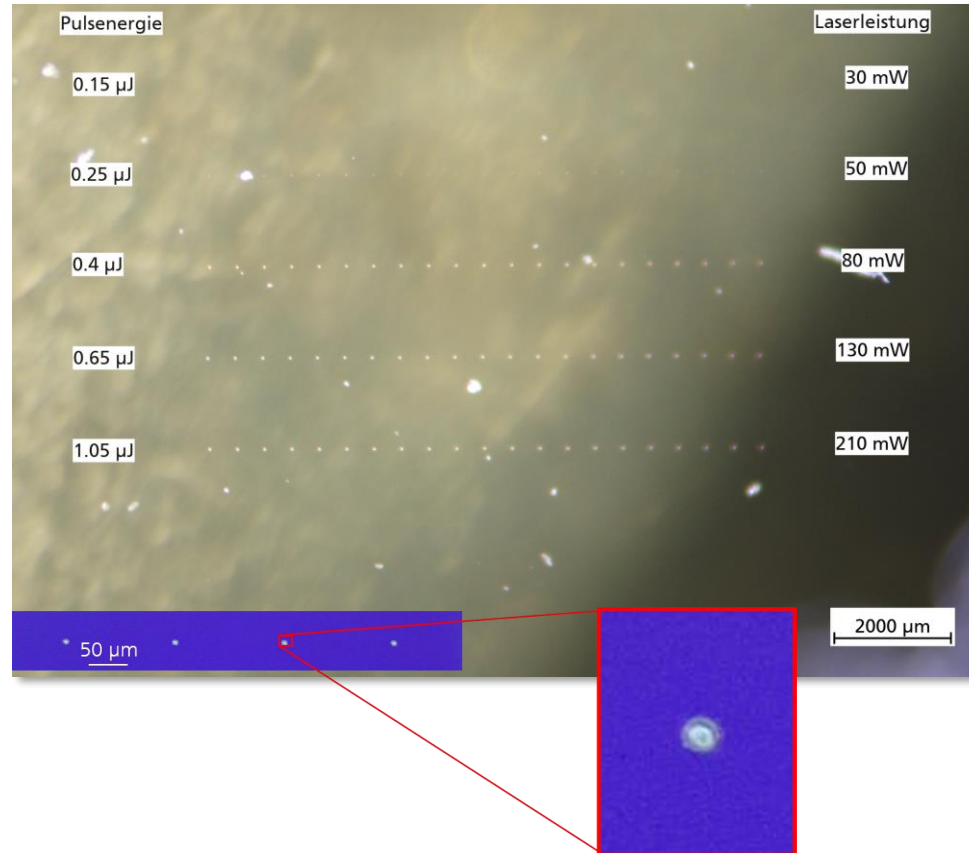
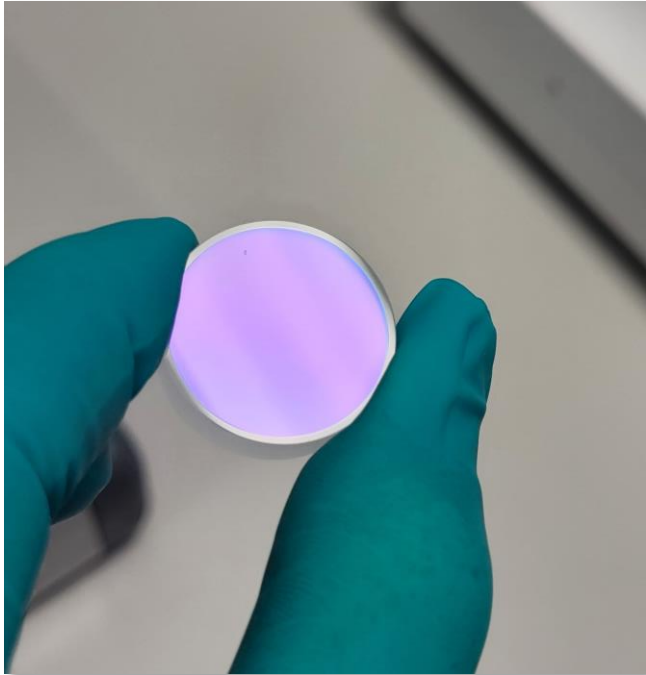


- ToF-SIMS depth profiles:
  - Main AR components
  - Contaminants (sample surface, AR/HC interface)
  - Organic depth profiling
  - Detection of volatile components



# Laser mirror coatings

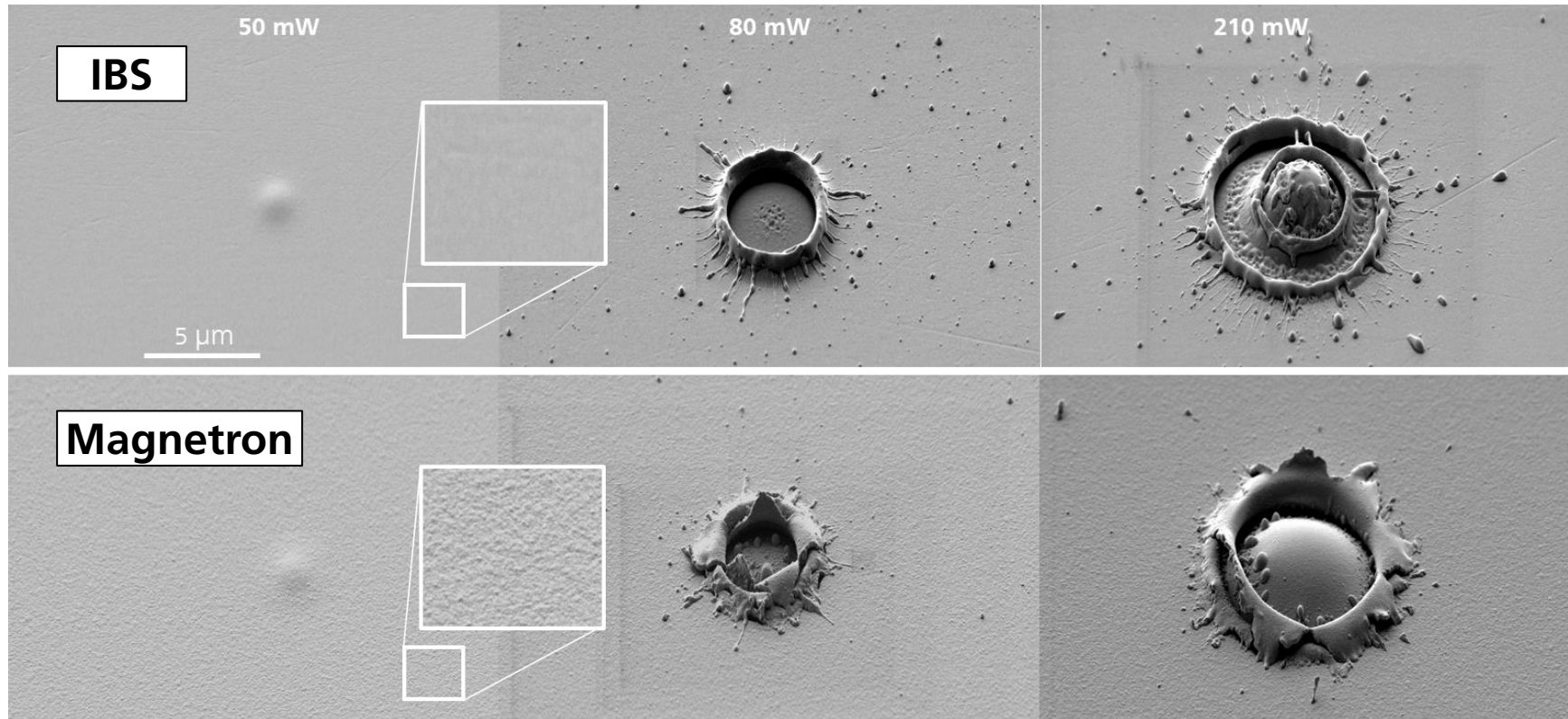
State of the Art Methods applied to (damaged) Laser Mirrors



- 2 purchased laser mirrors (355 nm):
- Reverse engineering
- Laser damage evaluation:
  - Focused laser @514 nm, 211 fs, 30-210 mW

# Laser mirror coatings

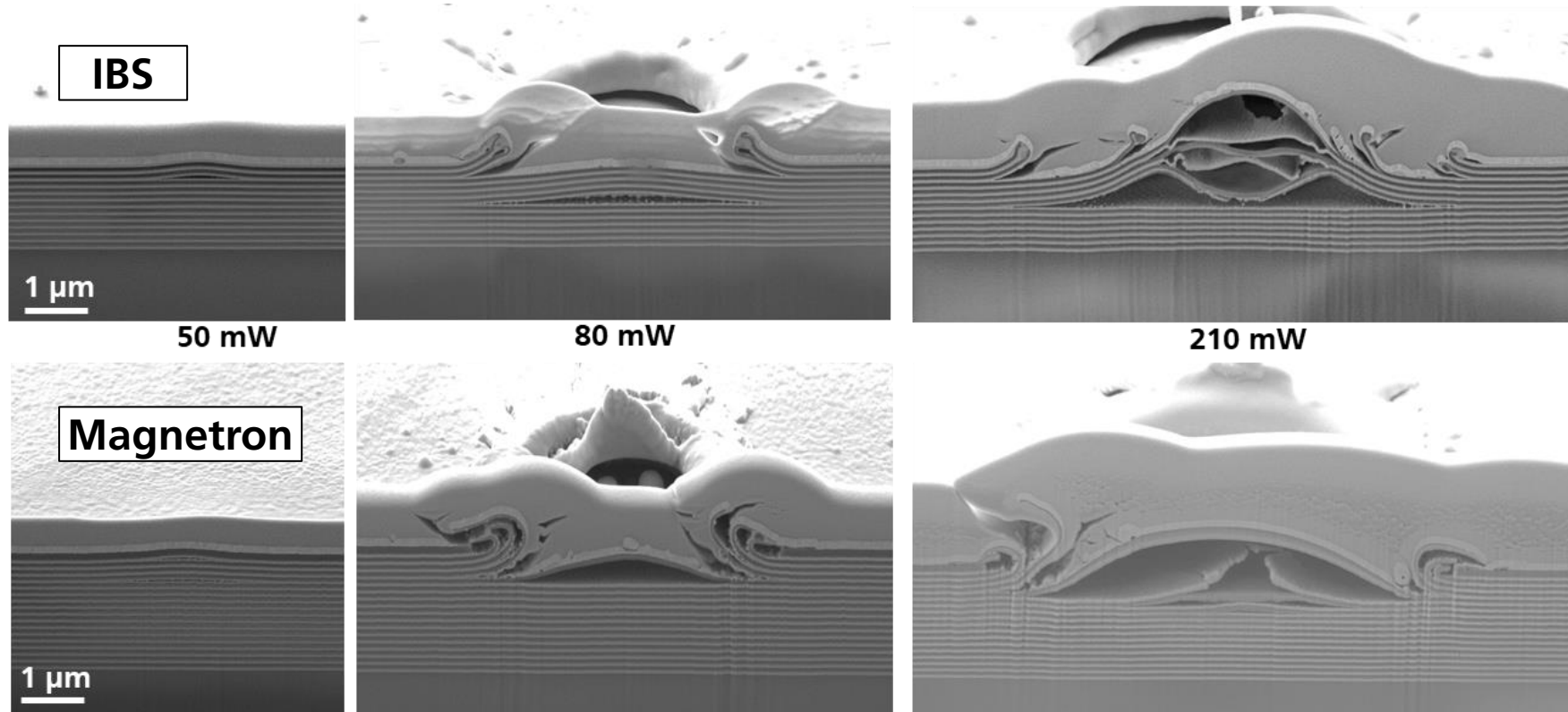
## SEM



- 2 purchased laser mirrors (355 nm):
- Laser damage evaluation:
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# Laser mirror coatings

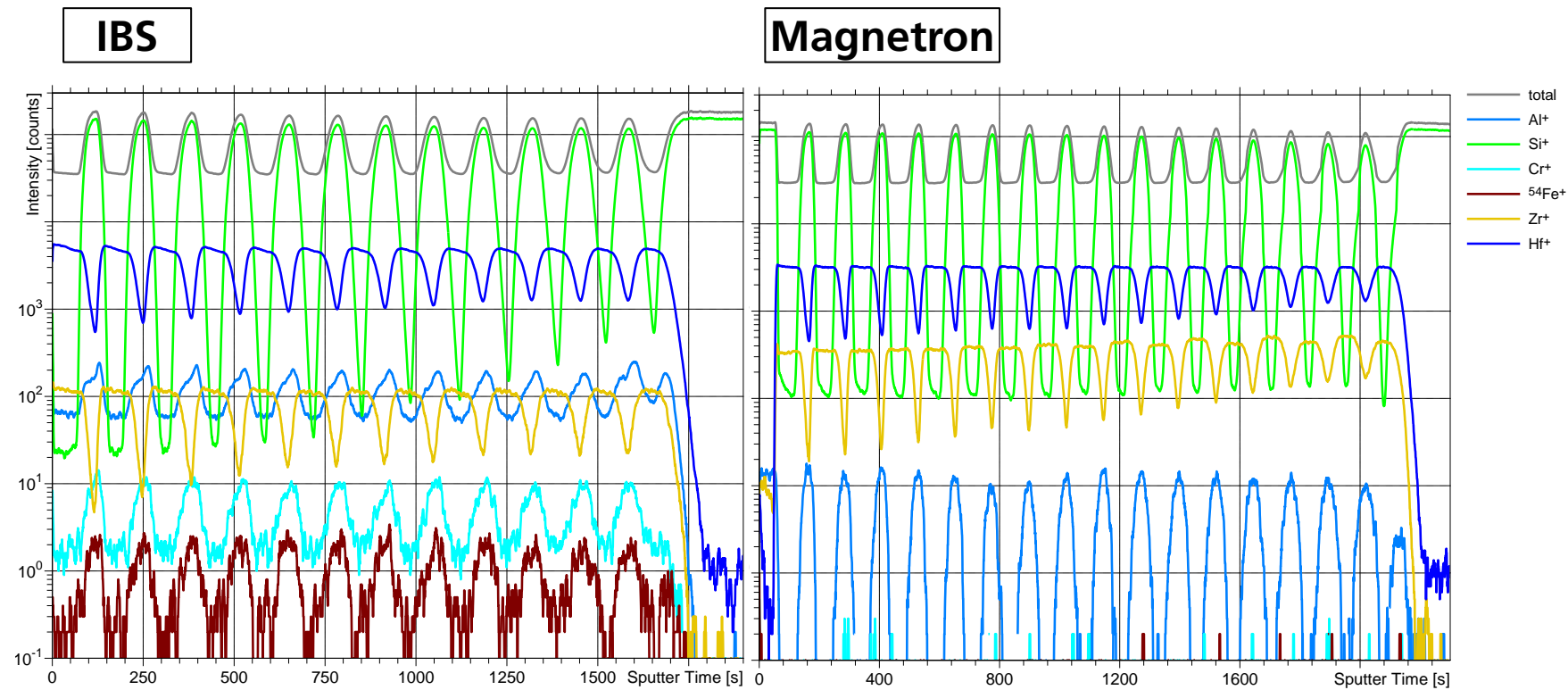
SEM + FIB



- 2 purchased laser mirrors (355 nm):
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# Laser mirror coatings

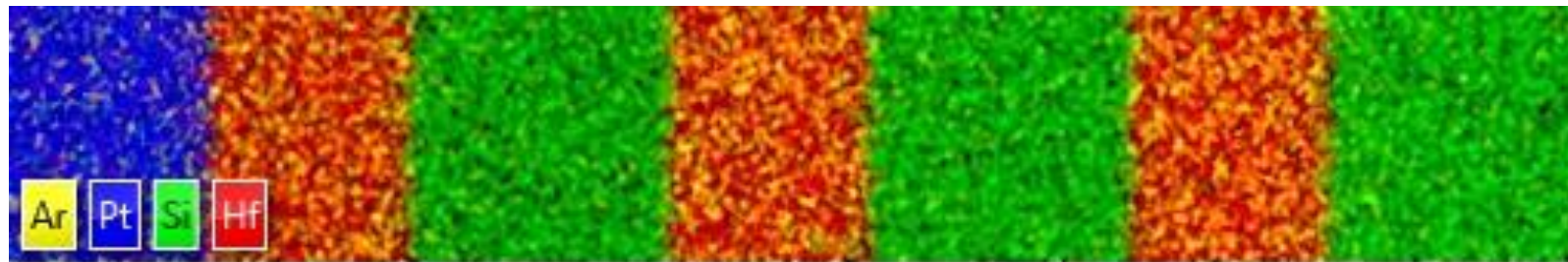
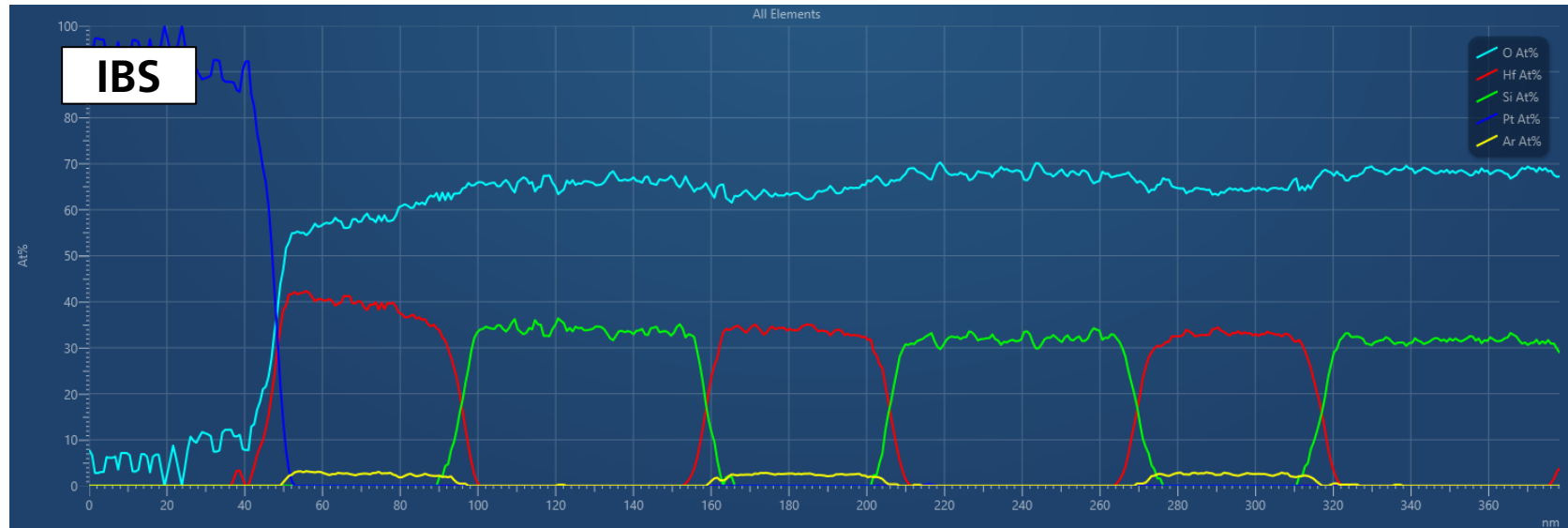
## ToF-SIMS



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  - Contaminations

# Laser mirror coatings

## STEM-EDX

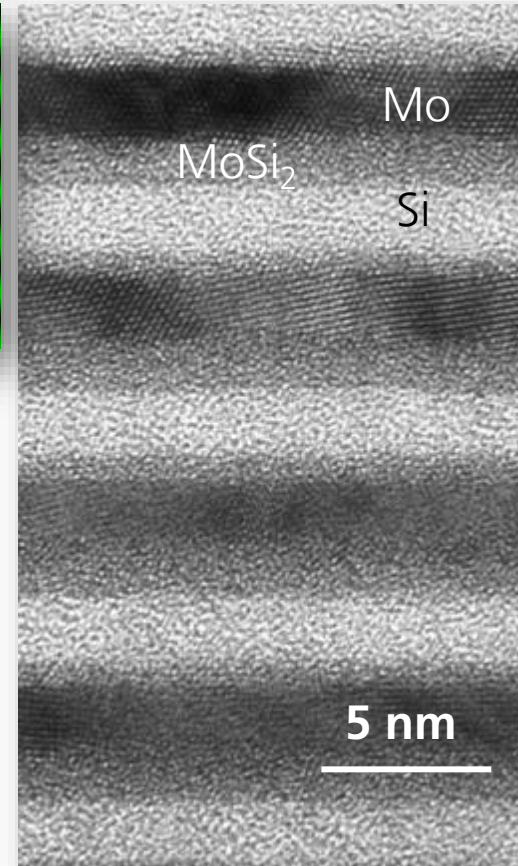
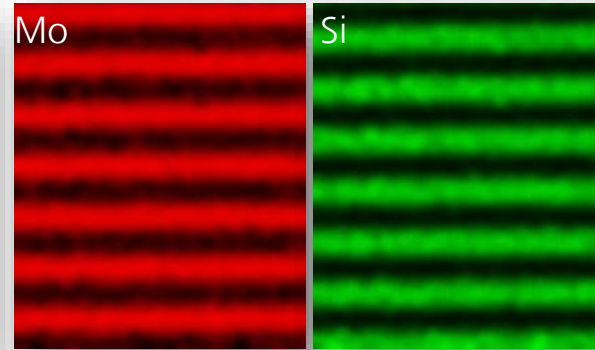
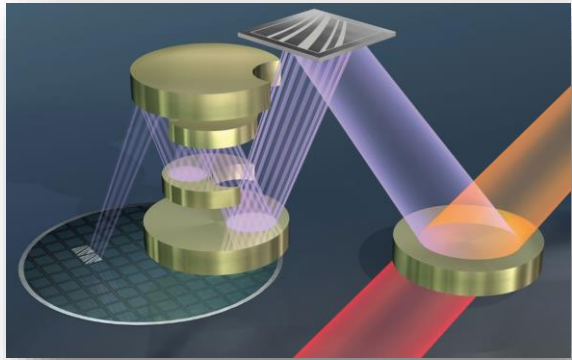


Magnetron

- 2 purchased laser mirrors (355 nm):
- Reverse engineering
  - Contaminations
  - Process information (Ar in HfO<sub>2</sub>)

# Microstructure Analysis

## State of the Art Methods Applied to EUV Multilayers



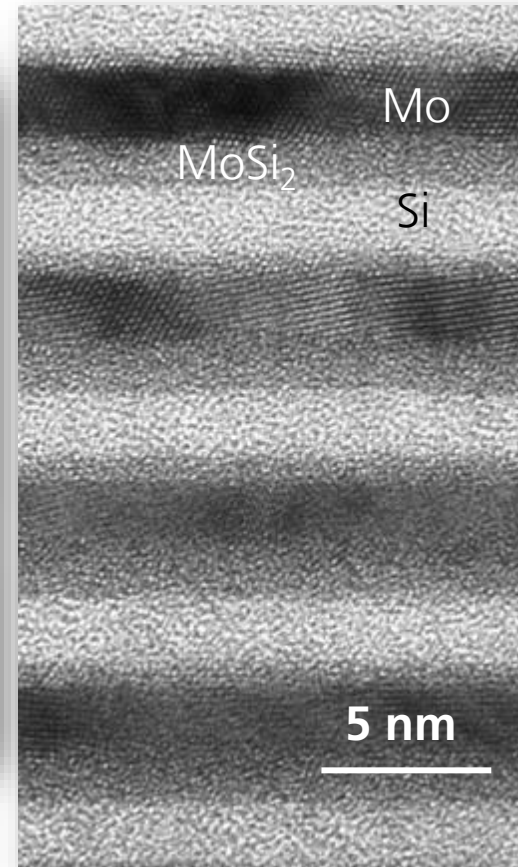
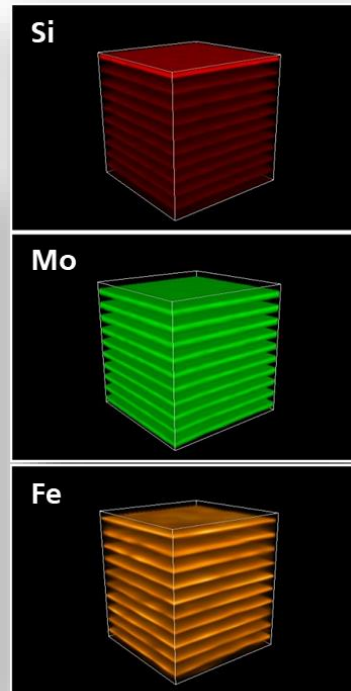
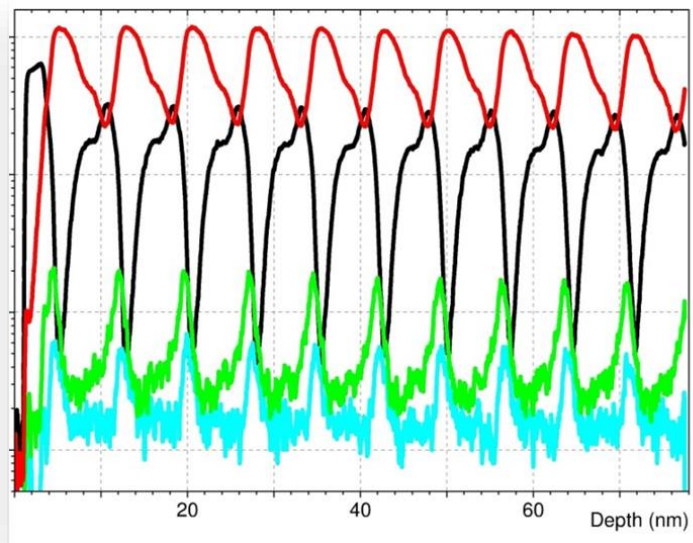
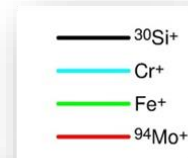
<https://www.fraunhofer.de/de/forschung/aktuelles-aus-der-forschung/euv-lithographie.html>

- EUV: huge market, demanding systems.
- TEM:
  - Layer thickness, homogeneity, crystallinity.
  - Interface layers discernable.

# Microstructure Analysis

## State of the Art Methods Applied to EUV Multilayers

layer thicknesses: Mo 3,5 nm  
Si 3,8 nm

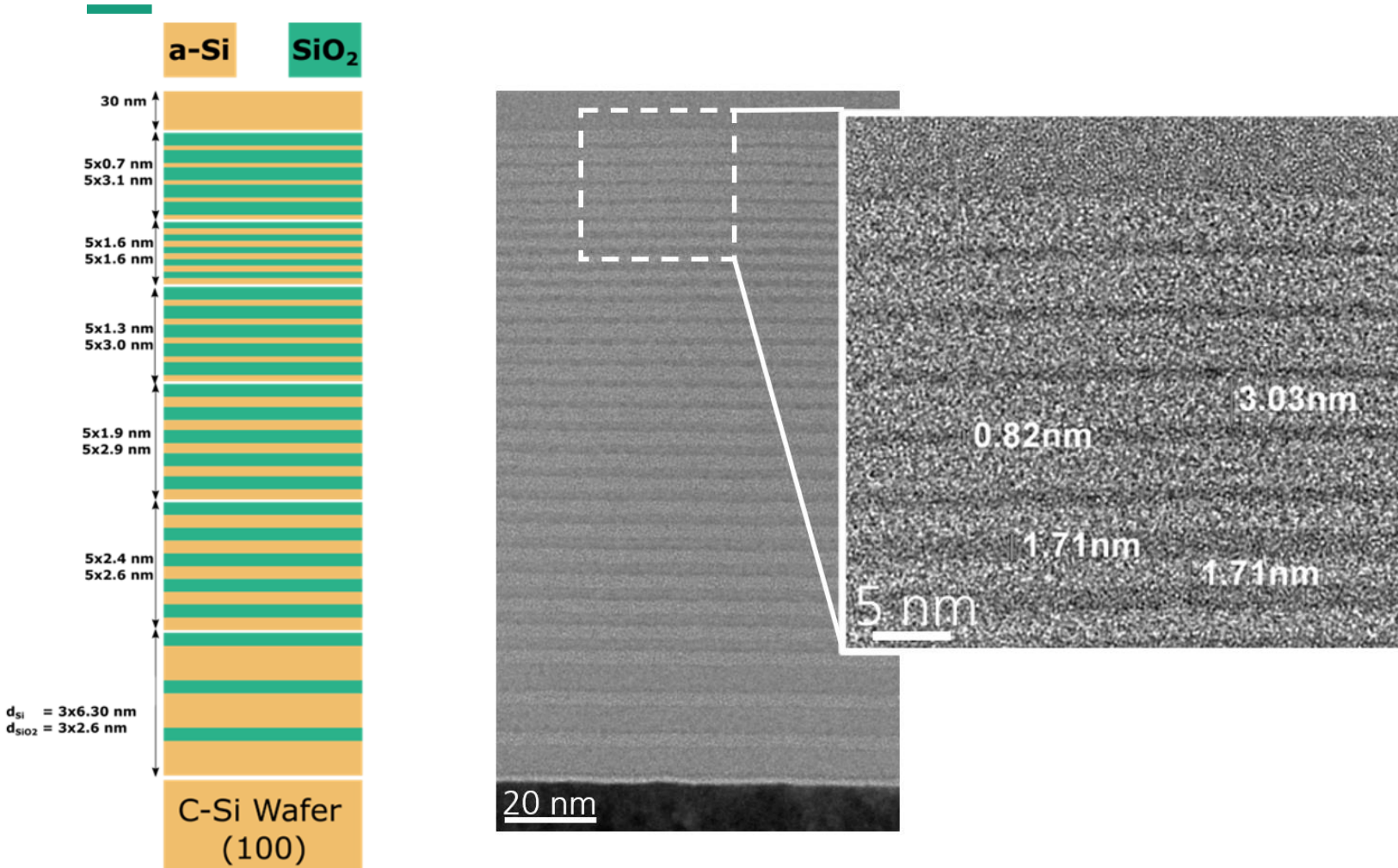


- EUV: huge market, demanding systems.
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  - Interface layers discernable.
- ToF-SIMS:
  - contaminations



# Ultra Thin Films: Nanolaminates

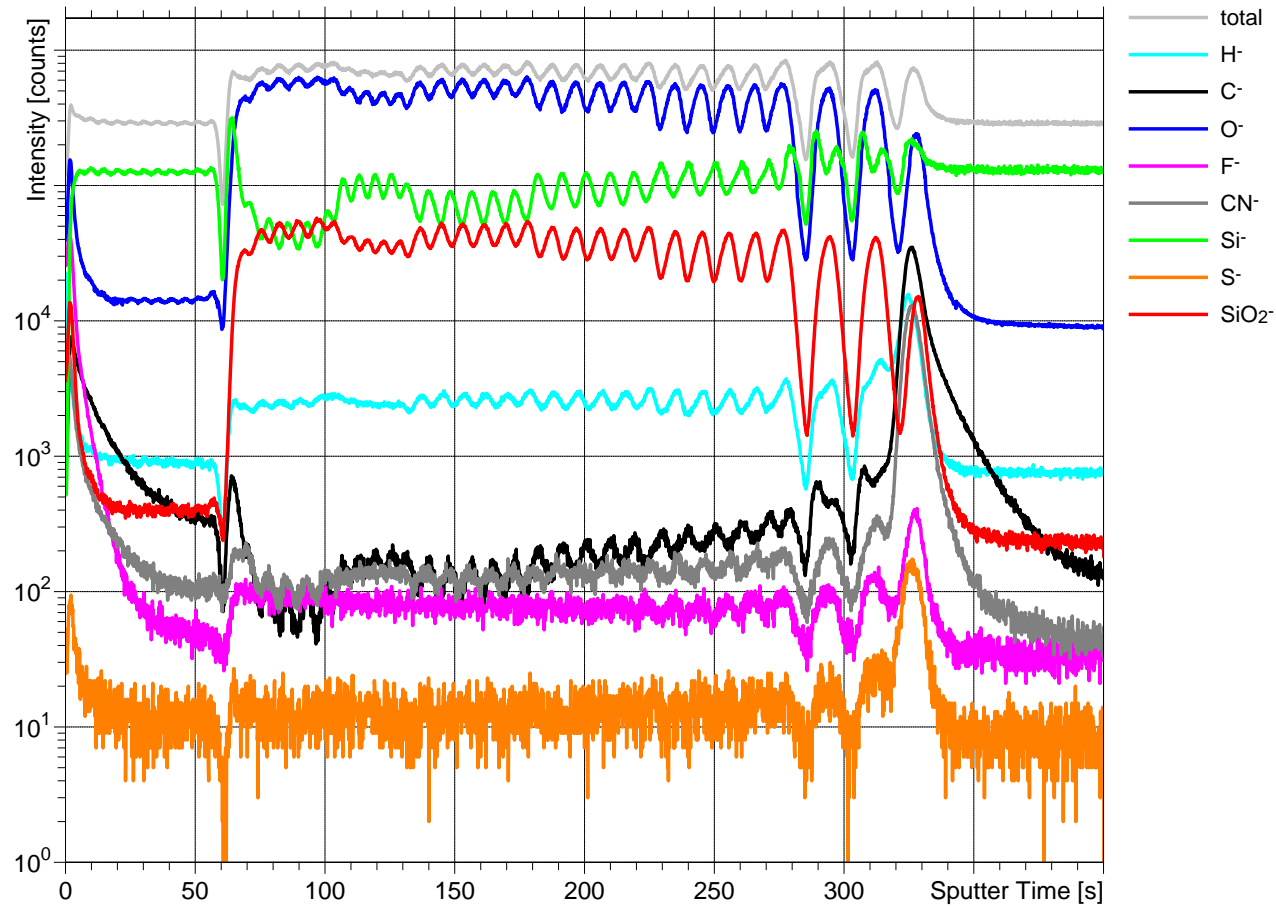
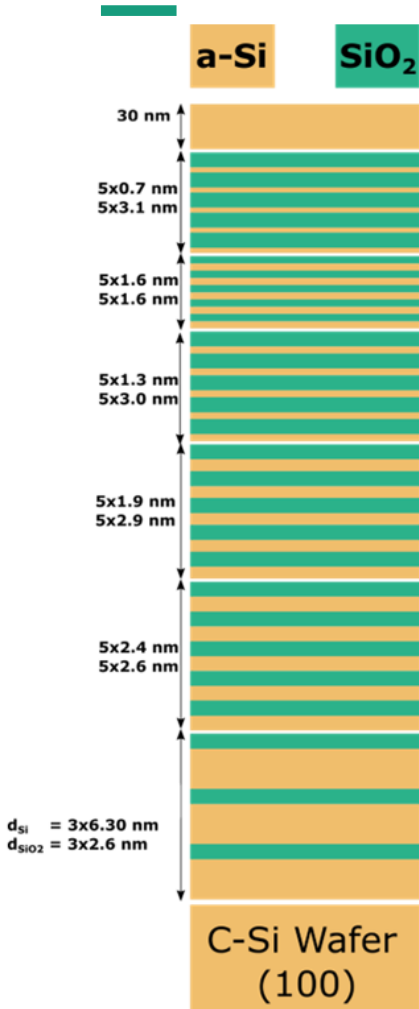
## HR-TEM



- Nanolaminates: multi-quantum well structures with tuneable band gap/refractive index.
- HR-TEM of whole nanolaminate stack: precise thickness control.

# Ultra Thin Films: Nanolaminates

## ToF-SIMS



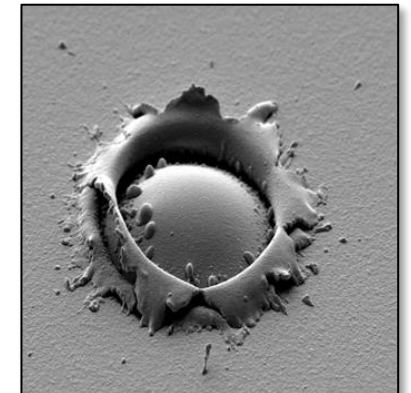
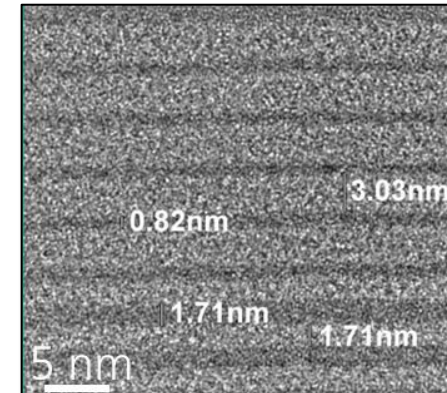
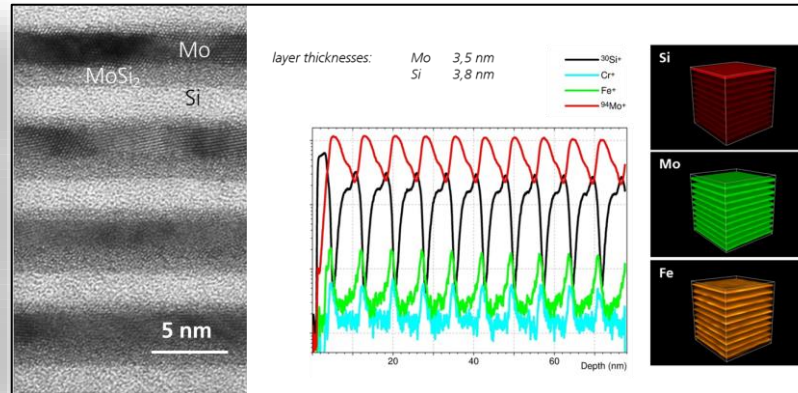
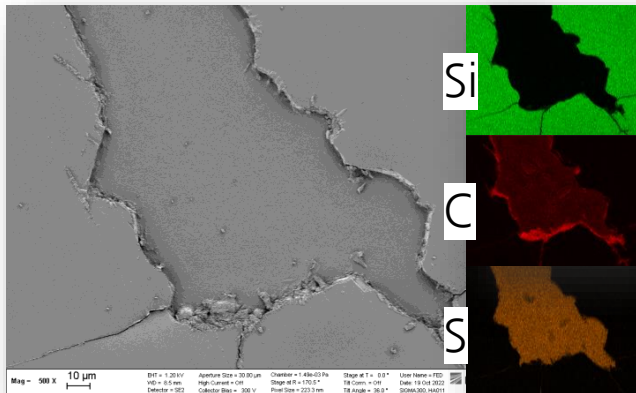
- Nanolaminates: multi-quantum well structures with tuneable band gap/refractive index.
- HR-TEM of whole nanolaminate stack: precise thickness control.
- ToF-SIMS: contaminations.

# Microstructural Thin Film Analysis

What is it Good for?

Having a look inside

- Direct results vs. indirect hints or conclusions based on assumptions
- Target (e.g. failure) regions can be directly assessed
- Combination of microstructural and chemical information
- **Microstructure-based process understanding reduces development times**



# Contact

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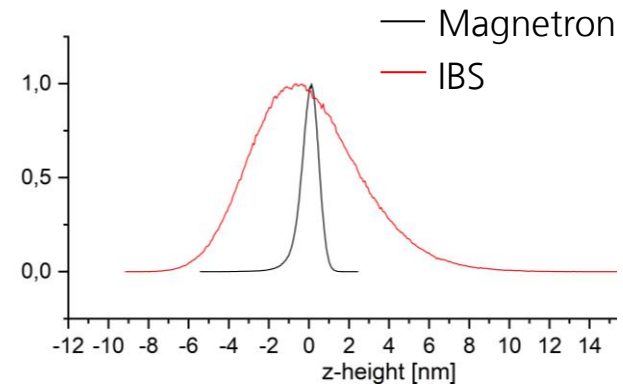
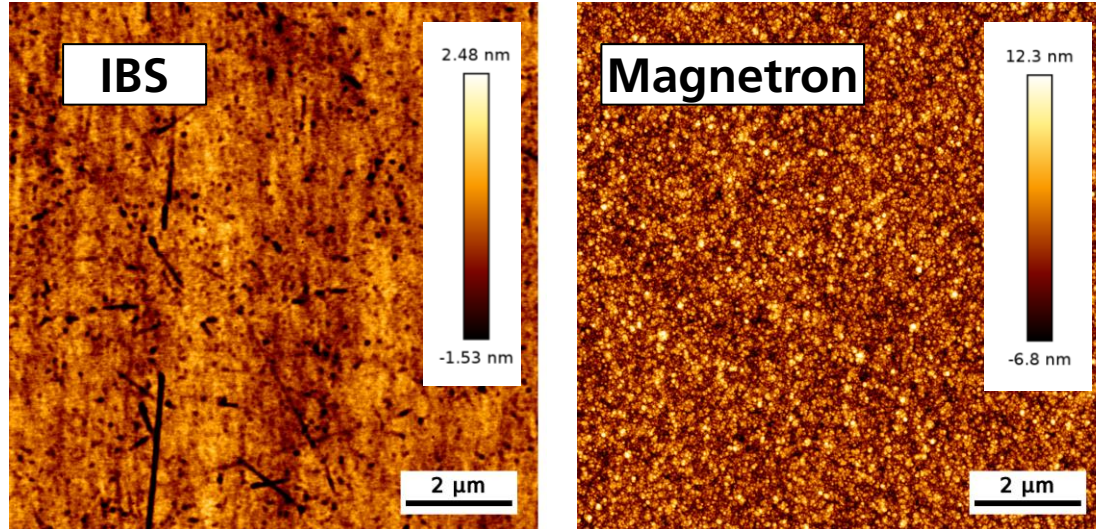
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# Laser mirror coatings

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